

# Magnetic anisotropies effect on the Spin-Seebeck response in spinel ferrite thin films

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## Introduction

Observation of spin Seebeck effect (SSE) at room temperature in a weak ferromagnetic material, for example, a spinel zinc ferrite ( $ZnFe_2O_4$ ) in bulk and thin film is demonstrated. In order to understand the physics behind this effect, a systematic structural and magnetic characterization with the SSE signal in this ferrite is presented. Measurements of surface analysis by x-ray photoemission (XPS) and absorption (XAS) spectroscopies, and x-ray magnetic circular dichroism (XMCD) provide information about the cationic distribution in the lattice, which is found to be responsible of the magnetic response in the material. The magnetic anisotropy, as well as the Gilbert constant of the ferrite have been investigated by means of ferromagnetic resonance measurements. These measurements are useful to predict the spin Seebeck response in the material.

## Experimental process

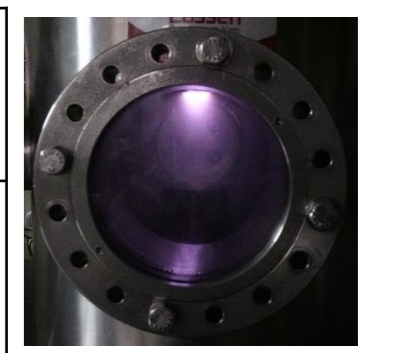


Fig. 1. ZFO target preparation process.

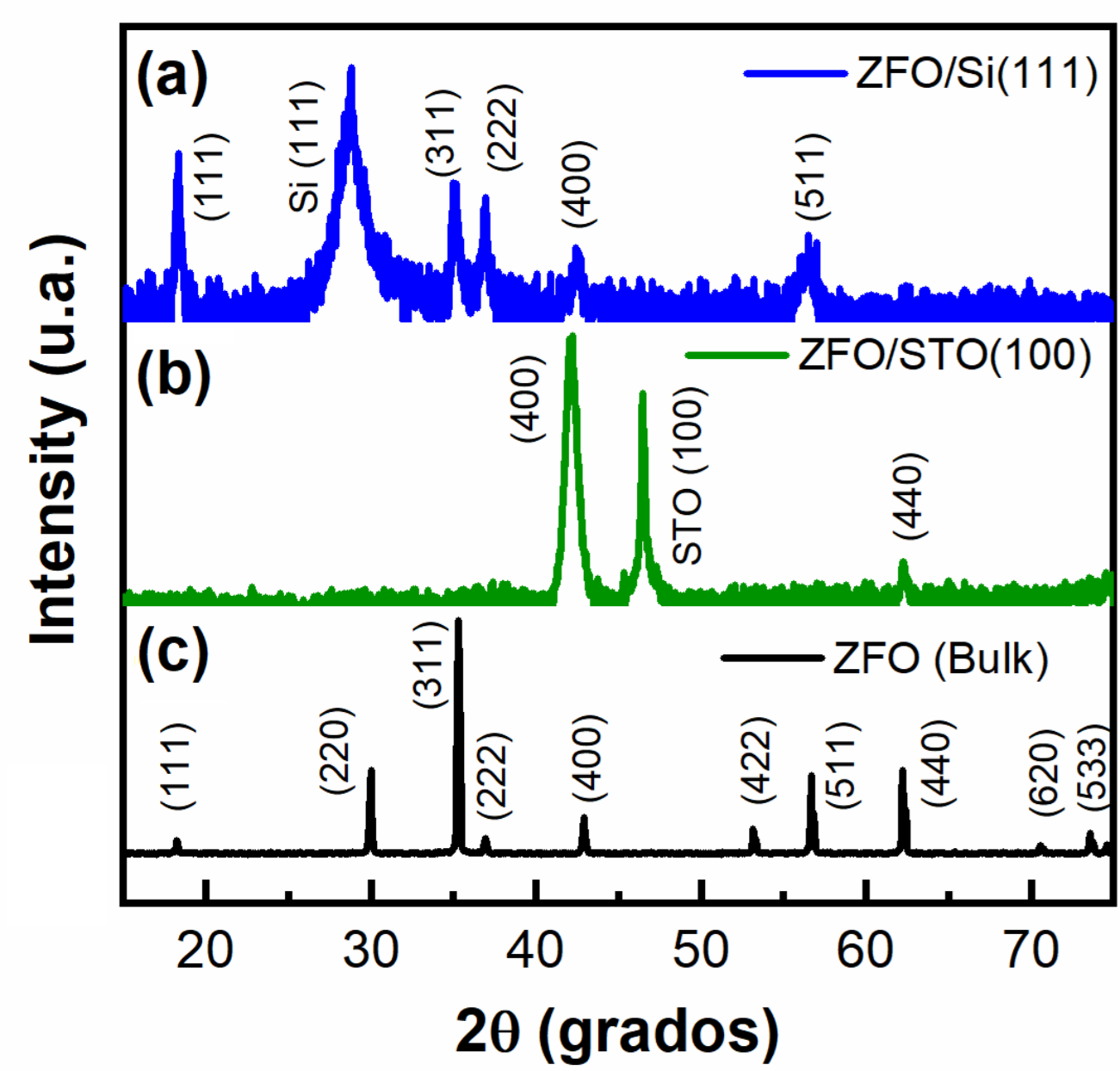
### Growth conditions thin films

ZFO thin films were grown using RF magnetron sputtering.

Gas pressure	Growth temperature	Ar/O <sub>2</sub> ratio	Thickness
27 mTorr	500 °C	2:1	90 nm



## STRUCTURAL CHARACTERIZATION



Sample	Lattice parameter
ZnFe <sub>2</sub> O <sub>4</sub> (Bulk)	8.44 Å
Thin film	8.43 Å

Fig. 2. XRD patterns of the ZnFe<sub>2</sub>O<sub>4</sub> in bulk and ZFO thin films on Si (111) and STO (100) substrates growth under Ar/O<sub>2</sub> = 1:2

## Results

## MAGNETIC CHARACTERIZATION

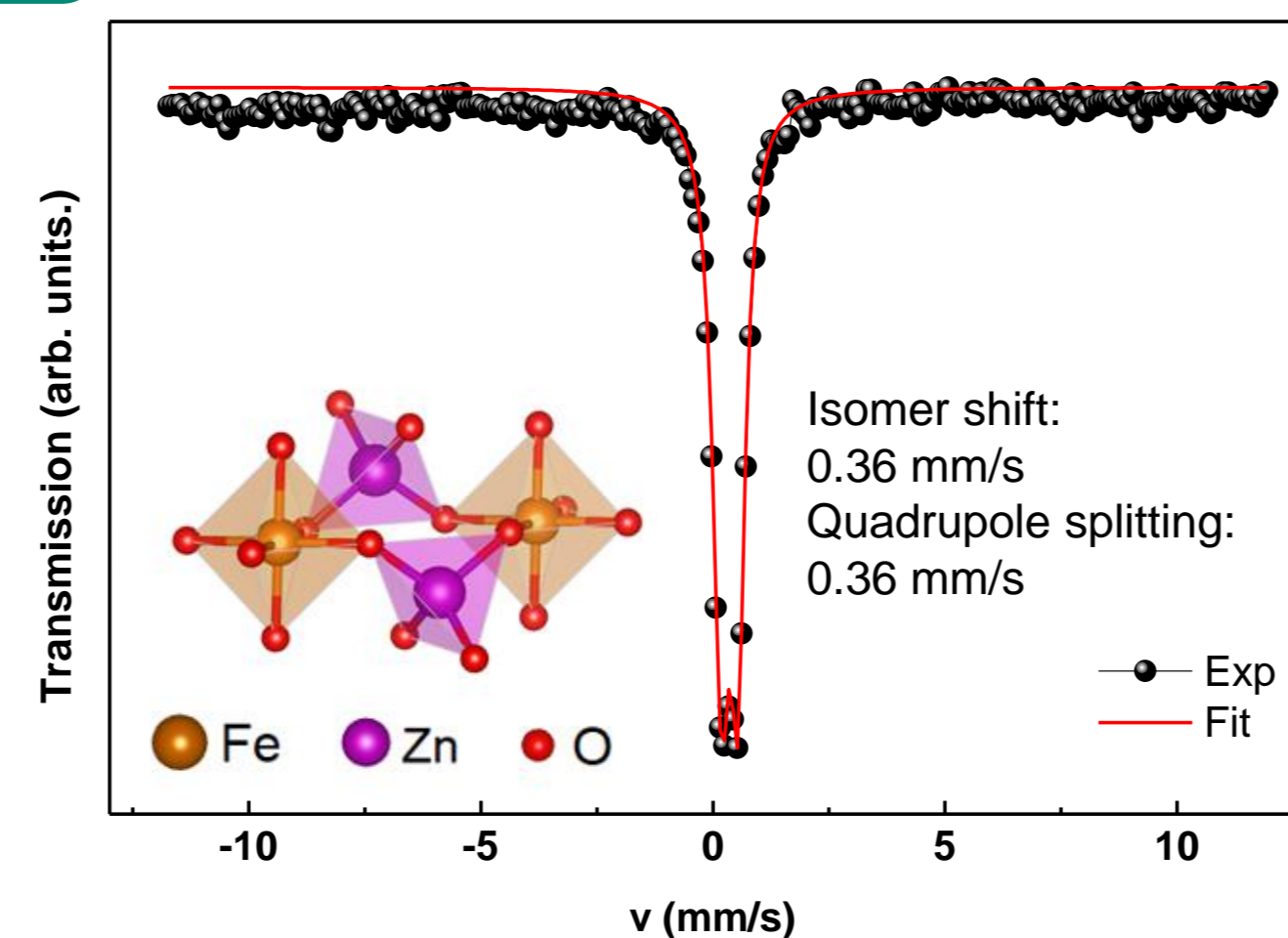
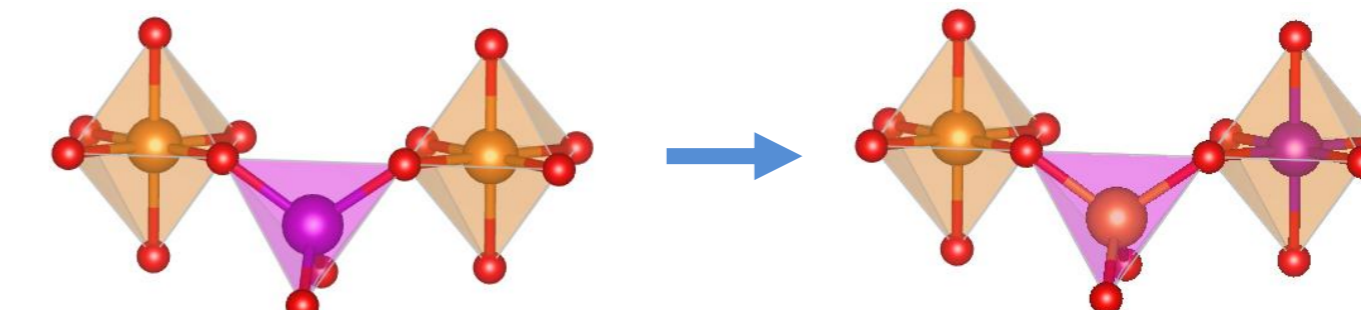


Fig. 3. Mössbauer spectra of ZFO in bulk. The red line corresponds to a fitting of the experimental data using the Recoil software.

Corresponding to characteristic Fe<sup>3+</sup> charge state in a direct spinel structure.



Superexchange interaction  
A-O-B ( $J_{AB}$ ) is the strongest,  
B-O-B ( $J_{BB}$ ) is weaker,  
A-O-A ( $J_{AA}$ ) is the weakest.

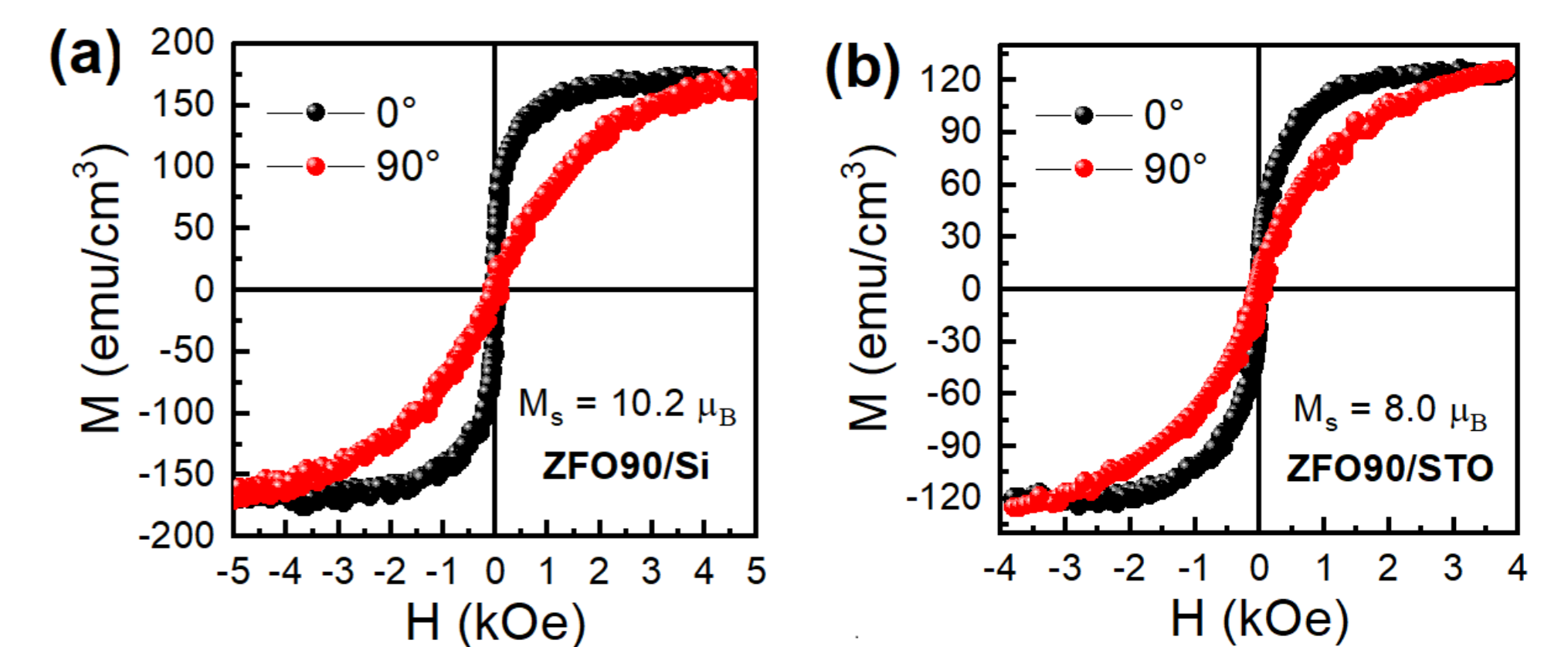


Fig. 4. Room temperature in-plane (0°) and out of plane (90°) magnetic hysteresis loops of ZFO thin films.

## XPS ANALYSIS

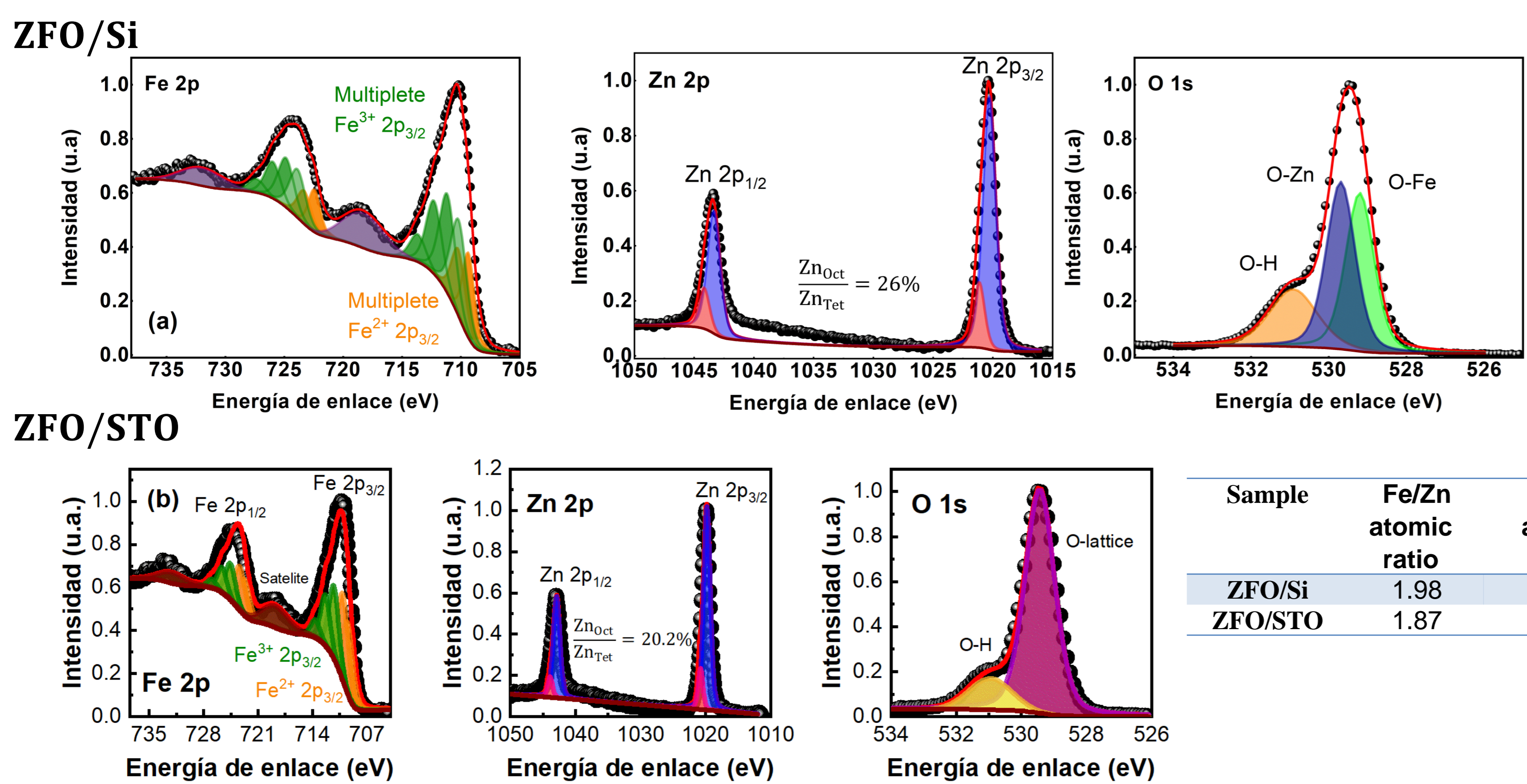


Fig. 5. a) XPS spectra for the thin films (a) ZFO/Si(111) (b) ZFO/STO(100). Symbols represent experimental data and lines represent the fit.

Sample	Fe/Zn atomic ratio	O/Zn atomic ratio
ZFO/Si	1.98	8.74
ZFO/STO	1.87	5.41

## FERROMAGNETIC RESONANCE

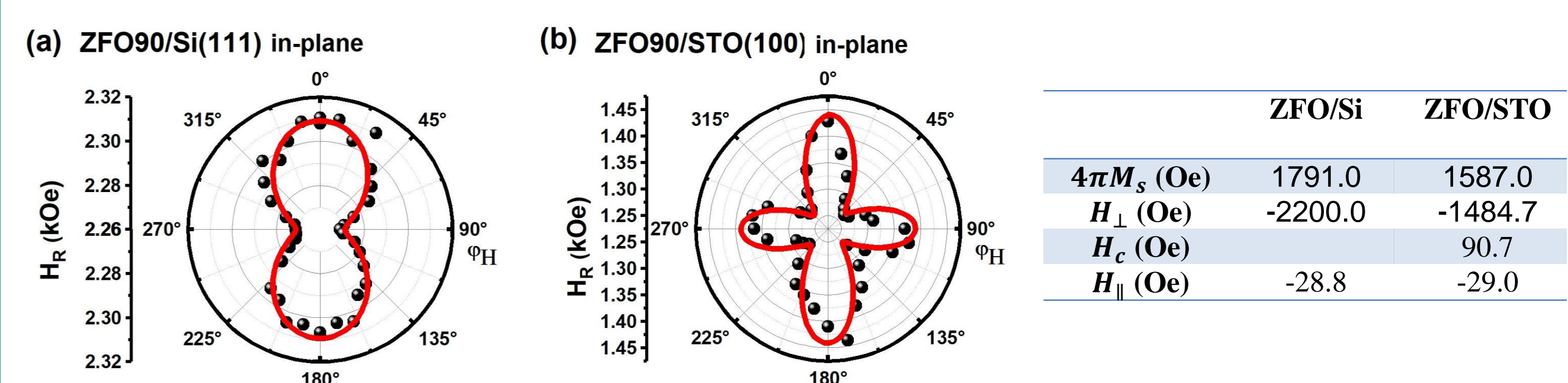


Fig. 8. Ferromagnetic resonance field as a function of the in-plane azimuthal angle  $\phi_H$  for ZFO/Si and ZFO/STO. The red solid lines are theoretical fits to the experimental data (black spheres).

## LONGITUDINAL SPIN SEEBECK EFFECT

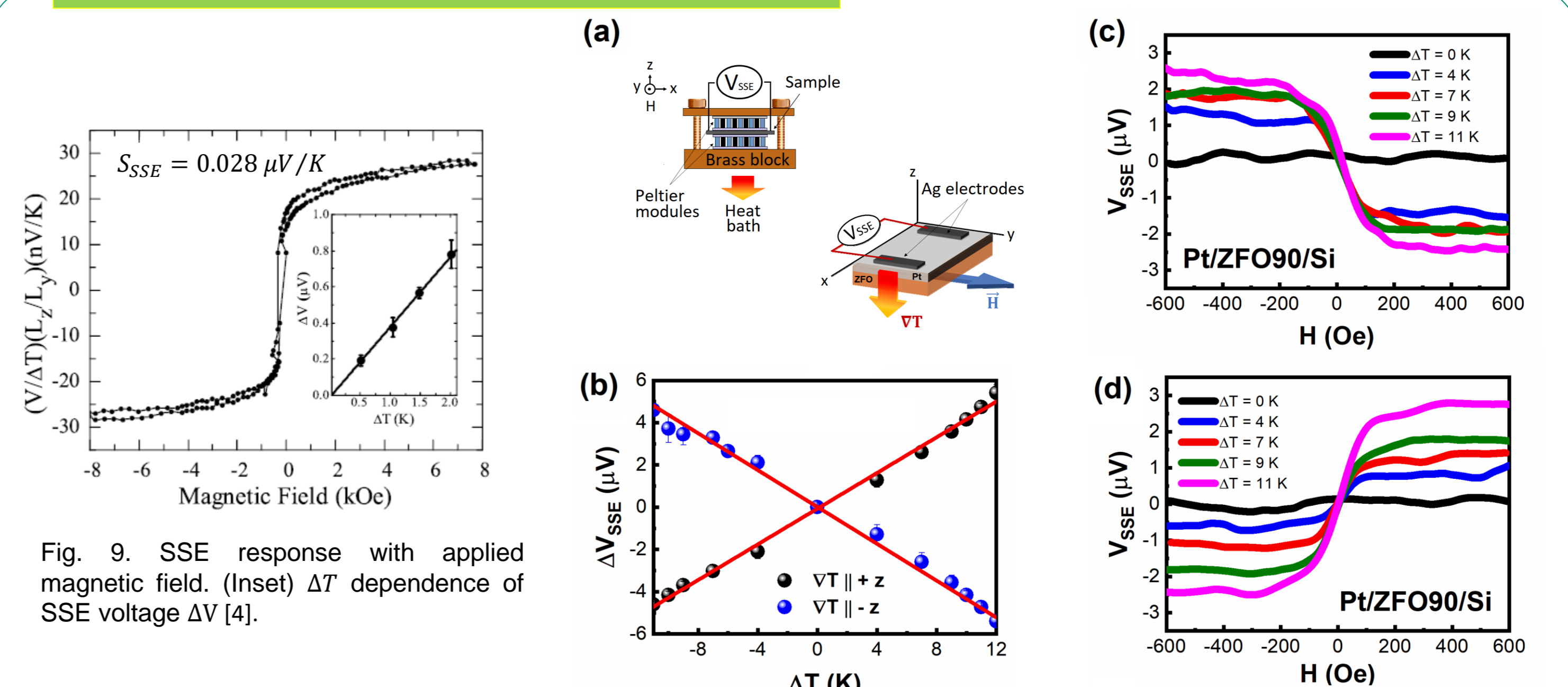


Fig. 9. SSE response with applied magnetic field. (Inset)  $\Delta T$  dependence of SSE voltage  $\Delta V$  [4].

Fig. 10. (a) Schematic illustration of the LSSE experimental set-up. (b) Variation of the voltage with  $\Delta T$  when the temperature gradient is applied along the +z and -z. (c) and (d) Variation with the magnetic field of the  $V_{SSE}$  measured on the Pt layer for different values of  $\Delta T$  for Pt/ZFO90/Si as indicated.

Thin film	$S_{SSE}$ ( $\mu V/K$ )	$\kappa_{sub}$ ( $W/mK$ )	$\alpha_{Gilbert}$
ZFO/Si	0.003	148	0.022
ZFO/STO	0.11	12	0.035

## XAS AND XMCD ANALYSIS

XAS and XMCD measurements were performed on beamline 6.3.1 at the Advanced Light Source (Berkeley, USA). Technical details of the measurements: energies around Fe L<sub>2,3</sub> edges, temperature of 300 K, magnetic field of  $\pm 1$  T applied at 30° from the sample plane, detection method was total electron yield.

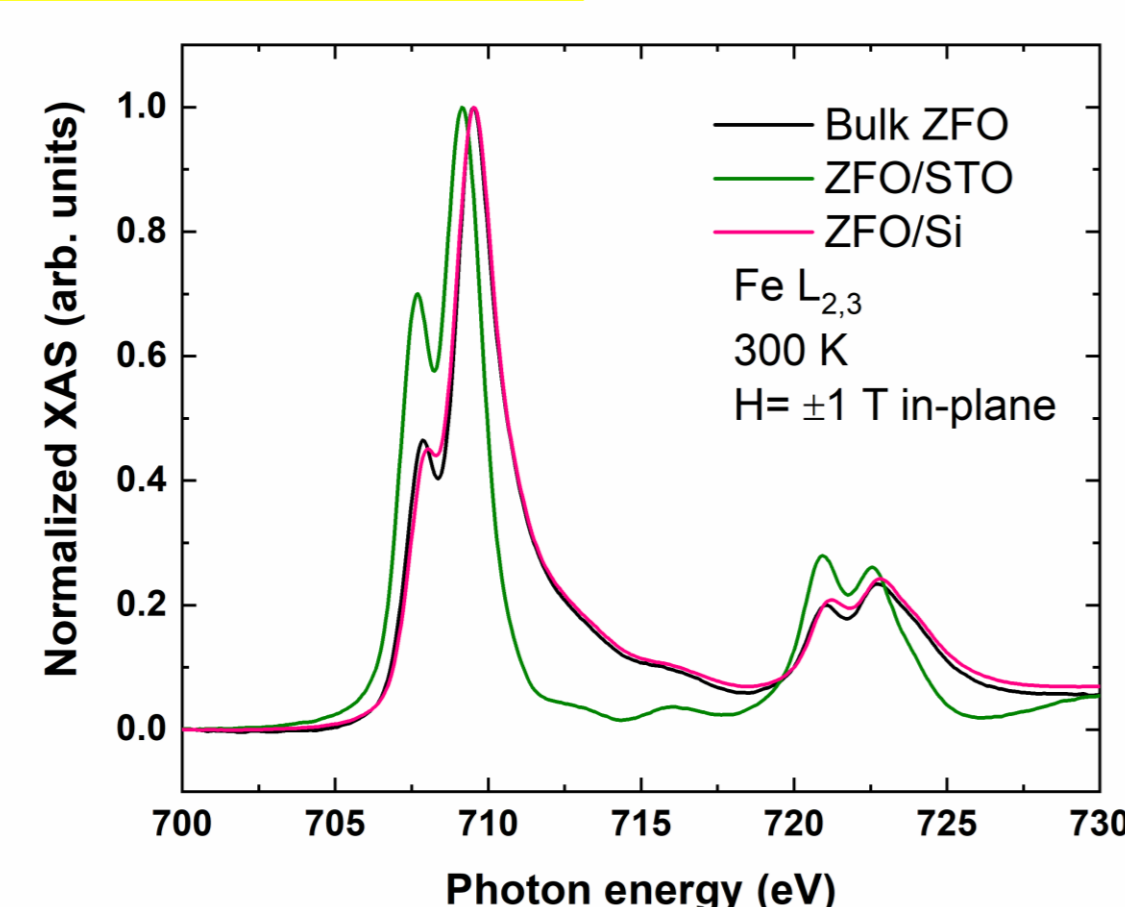


Fig. 6. Comparison of the normalized XAS for the bulk ZFO sample and the thin films grown on Si and STO. An evident shift towards lower energies, indicative of a lower valence (e.g. Fe<sup>2+</sup>), is observed on the ZFO/STO sample.

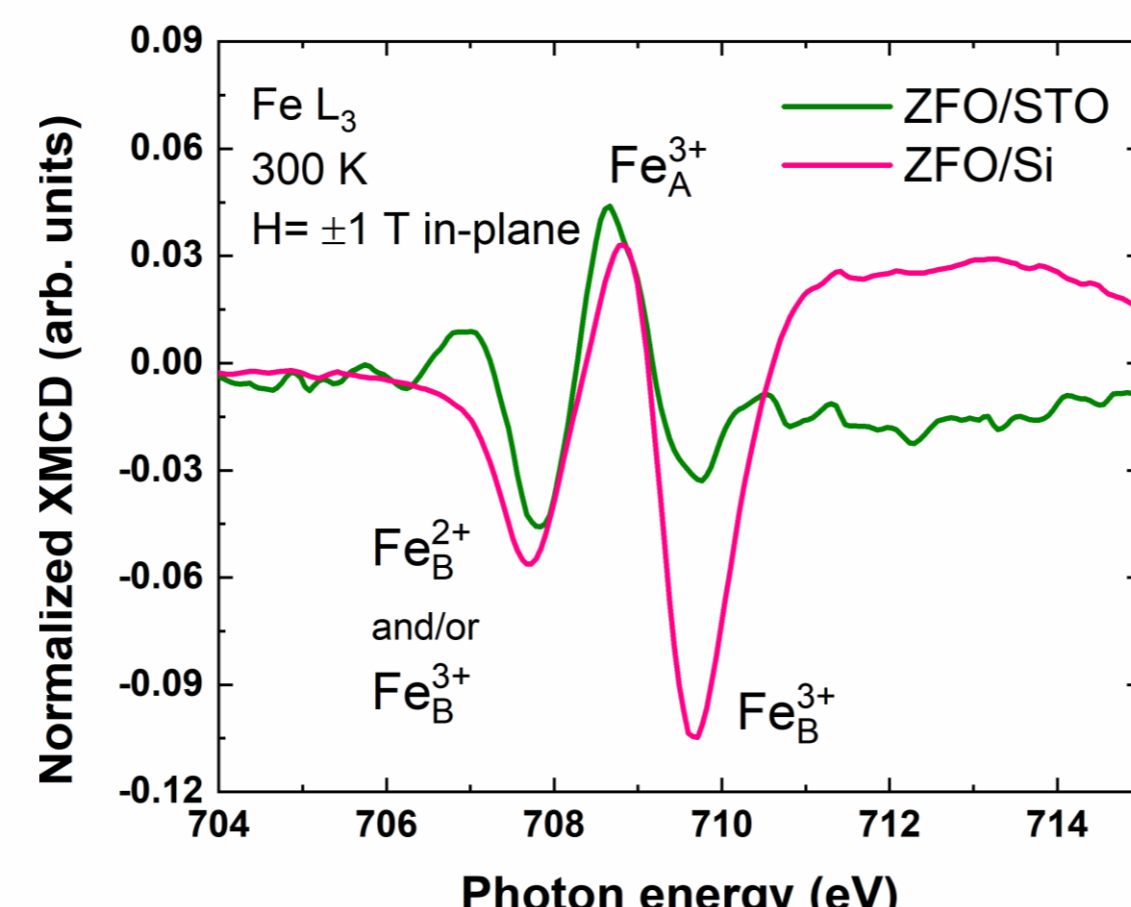


Fig. 7. Normalized XMCD results for the ZFO/Si and ZFO/STO thin films. A larger intensity is observed for ZFO/Si, consistent with a higher value of magnetization for that sample. The intensity is more pronounced for the sites occupied by Fe<sup>3+</sup> in octahedral environment, suggesting a larger component for this sample.

## Conclusion

The spin Seebeck coefficients extracted from the data for the thin films were highly sensitive to the thermal conductivity of the thin film and the substrate. Therefore, before measuring the Seebeck response in a material, it is important to pay more attention to the growth of the magnetic layer, and the choice of substrate.

The lattice mismatch and the presence of anisotropies in the sample can significantly change the magnitude of LSSE voltage; also, the type of substrate plays an important role in the calculated spin Seebeck coefficient.

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## References

- [1] Rastogi, A., Li, Z., Singh, A. V., Regmi, S., Peters, T., Bougiatioti, P. & Gupta, A. Physical Review Applied, 14(1), 014014 (2020).
- [2] P. Jiménez-Cavero, I. Lucas, D. Bugallo, C. López-Bueno, R. Ramos, P.A. Algarabel, M.R. Ibarra, F. Rivadulla, L. Morellón, Appl. Phys. Lett. 118 (2021).
- [3] Gil-Monsalve, J., Abrão, J. E., Santos, E., Ricalde, A., Azevedo, A., & Arnache, O. Physical Review B, 105(1), 014420 (2022).
- [4] JD Arboleda, O Arnache and MH Aguirre, Solid State Communications, Vol. 270, p. 140-146 (2018).